Diffraction Radiation Test at CesrTA for Non-Intercepting Micron-Scale Beam Size Measurement

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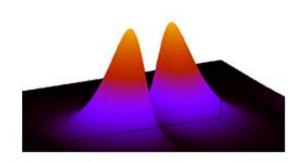
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- 2. CERN European Organisation for Nuclear Research, CERN, Geneva, Switzerland
- 3. Cornell University, Ithaca, New York, USA



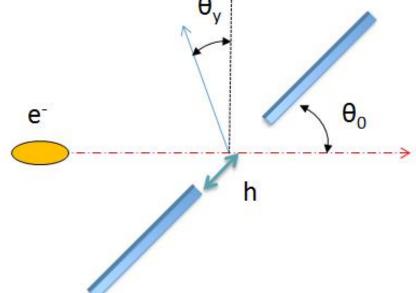
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Diffraction Radiation



DR Angular distribution



Principle:

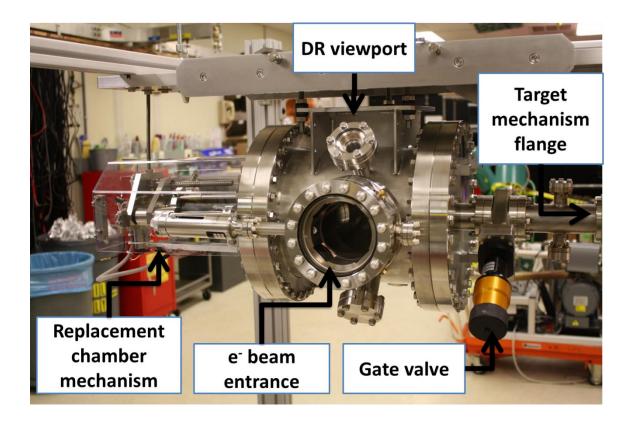
- 1. Electron bunch moves through a high precision co-planar slit in a conducting screen (Si + Al coating).
- 2. Electric field of the electron bunch polarizes atoms of the screen surface.
- 3. DR is emitted in two directions:
 - along the particle trajectory "Forward Diffraction Radiation" (FDR)
 - In the direction of specular reflection "Backward Diffraction Radiation" (BDR)

Impact parameter:

$$h \le \frac{\gamma \lambda}{2\pi}$$

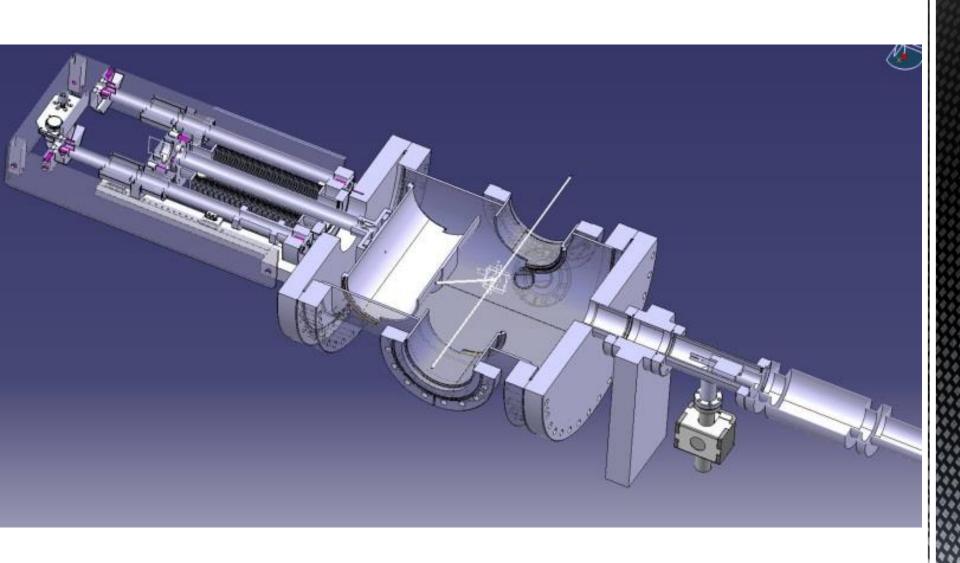
 θ_{γ} = observation angle in vertical direction θ_0 = target tilt angle λ = wavelength γ = Lorentz factor

Vacuum chamber assembly



- LHS: CHESS operation
- RHS: DR experiment
- Optical system connected to DR viewport

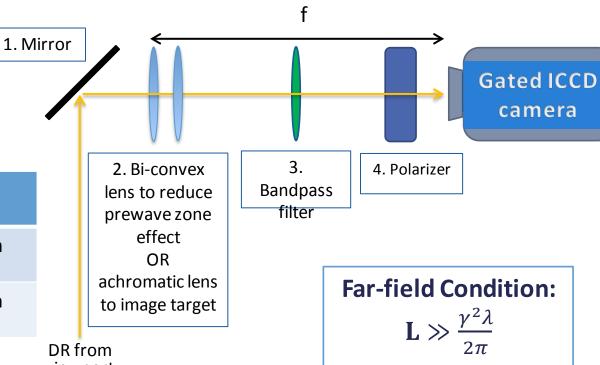
- Gate valve to disconnect CESR vacuum for target changeover
- Target mechanism: rotation + translation
 IN/OUT



Optical System

 $\frac{\gamma^2\lambda}{2\pi}$ given γ and λ :

	2.1 GeV	5 GeV
200 nm	0.54 m	3.18 m
400 nm	1.08 m	6.37 m



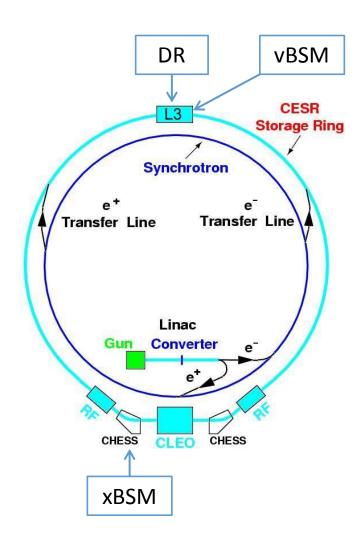


- L = distance from source of DR to detector
- Compact optical system is in the prewave zone therefore a biconvex lens is used with detector in back focal plane to obtain the angular distribution.

(Pre-wave zone effect in transition and diffraction radiation: Problems and Solutions -P. V. Karataev).



Instruments at CesrTA



http://www.cs.cornell.edu

DR:

- Located in L3 straight section
- Target is inserted from the radial outside

vBSM (Visible Beam Size Monitor)

• measures horizontal beam size σ_x (S. Wang et al., IPAC2013, MOPWA073, p.849.)

xBSM (X-ray Beam Size Monitor)

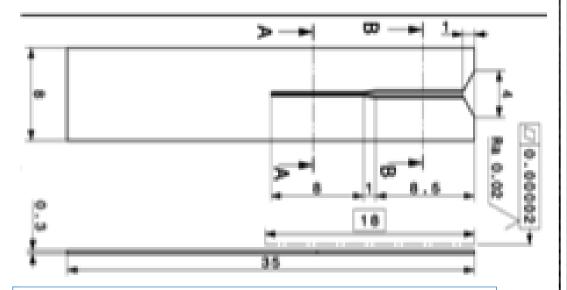
• measures vertical beam size σ_y (N. Rider et al., IBIC2012, WECD01, p.585.)

Beam lifetime + beam current monitor

Beam loss monitors downstream of DR target

Target





Aperture sizes: 0.5 mm and 1 mm (etched)

Material: Stainless steel (unpolished)

Thickness: 1 mm

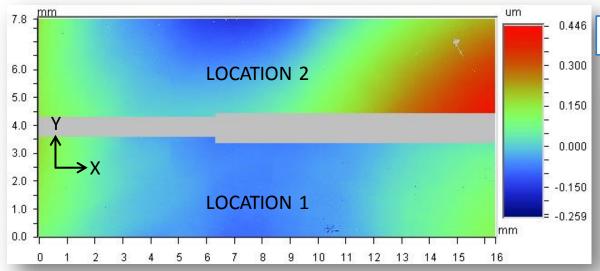
Tilt angle wrt beam: 70°



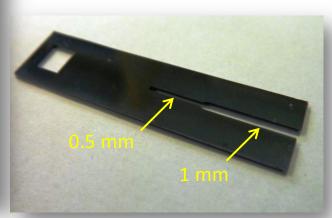


Technical drawings by N. Chritin Images by Y. Li

Chemically etched target







Specification	Location 1 (in µm or in µrad)	Location 2 (in μm or in μrad)
Maximum to minimum	0.64 μm	0.62 μm
Tilt in X direction	0 μrad	-17.6 μrad
Tilt in Y direction	0 μrad	37.9 μrad

Chemical etching:

A process where silicon wafers are dipped into an etchant which is traditionally an acidic mixture.

M.S. Kulkarni and H.F. Erk, Journal of The Electrochemical Soc., 147 (1) 176-188 (2000)





Tilt Y

mm

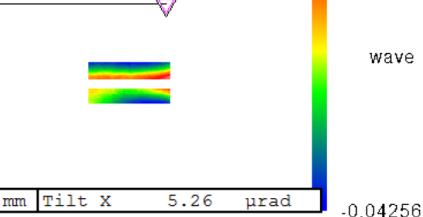
Pts in PV Spec (%)

+0.06566

wave



Molecular adhesion target (2mm version shown here). 1mm aperture version was used at CesrTA.



-59.30

"Bonding by molecular adhesion (either 'direct wafer bonding' or 'fusion bonding') is a technique that enables two substrates having perfectly flat surfaces (e.g., polished mirror surfaces) to adhere to one another, without the application of adhesive (gum type, glue, etc.)."

Size X

Size Y

9.96

4.98

Patent US 8158013 B2

Coplanarity measurement:

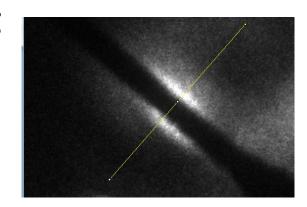
PV	68.479	nm
rms	13.909	nm

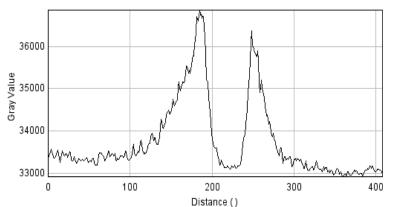
urad

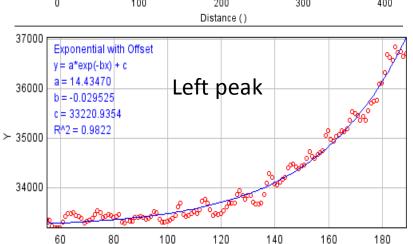
Metrology by Winlight Optics

Identification of DR in target imaging

- DR intensity decays exponentially from slit edge
- SR intensity uniform over small regions
- From simulations, max SR intensity (vert. pol.) does not occur at slit edge



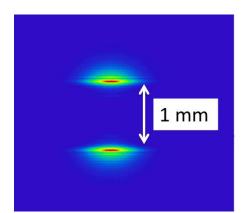




DR intensity $[ph/e^{-}] = k * SR$ intensity $[ph/e^{-}]$

 $k\sim$ 50 using real data from TR $k\sim$ 25 using DR images

DR vert. pol. $\sim 4.0 \times 10^{-5}$ ph/e⁻ SR. vert. pol. $\sim 6.3 \times 10^{-7}$ ph/e⁻



T. Aumeyr et al., IBIC2013, WEPF18.

DR target imaging

- 2.1 GeV
- 1 mA single- bunch beam
- 400 nm DR observation wavelength

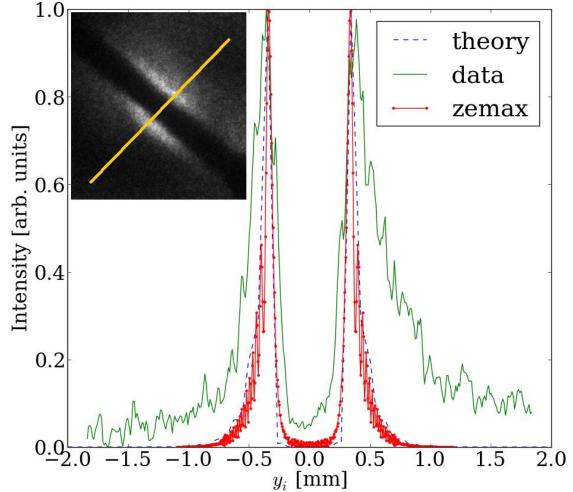
Theory-D. Xiang et al., Phys. Rev. ST Accel. Beams, 10 (2007) 062801.

Zemax-

T. Aumeyr et al., IBIC2013, WEPF18.

Data broadening possibly due to:

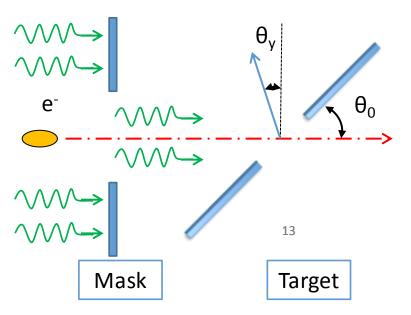
- data taken for $\sigma_y \sim 20~\mu m$ theoretical model and Zemax : single e⁻ $\sigma_v \rightarrow 0$
- Polariser misalignment → some horiz. pol. DR and synchrotron radiation (SR)
- 10 ± 2 nm bandwidth → data smearing (small)
- 15 ms exposure time (CesrTA rev. period $T = 2.56 \,\mu\text{s}$) \rightarrow smearing from beam jitter



Synchrotron Radiation (SR)

Source of background	Contribution	
SR from beamline optics	High	
Camera noise	low	
Residual background	LOW	

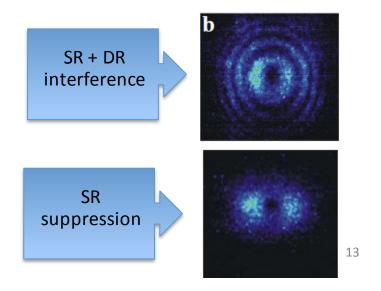
Use a mask upstream of target to suppress SR contribution.



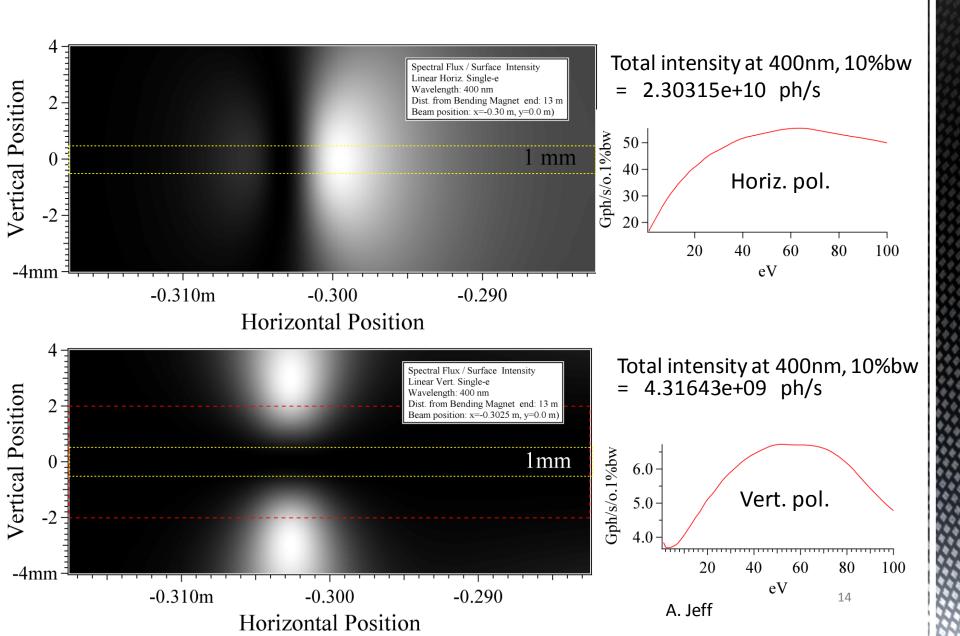
ODRI considerations:

Aperture sizes	Interference
$a_{\text{mask}} = a_{\text{target}}$	Complete destructive interference of FDR + BDR
a _{mask} ≈ 2·a _{target}	Measureable interference
$a_{\text{mask}} \ge 4 \cdot a_{\text{target}}$	Negligible interference

- A. Cianchi et al. Phys. Rev. S. T., 14 102893 (2011)
- P. Karataev et al., Proc. of EPAC 2004, THPLT067



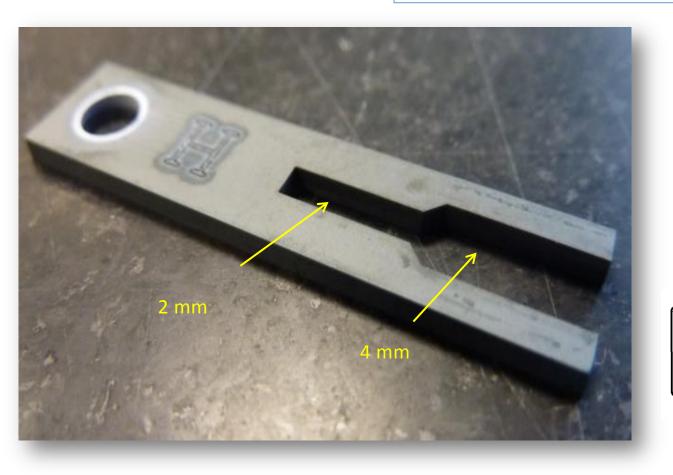
SRW simulations

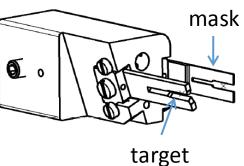


Mask

Technical drawings by N. Chritin, Metrology by L. Remandet

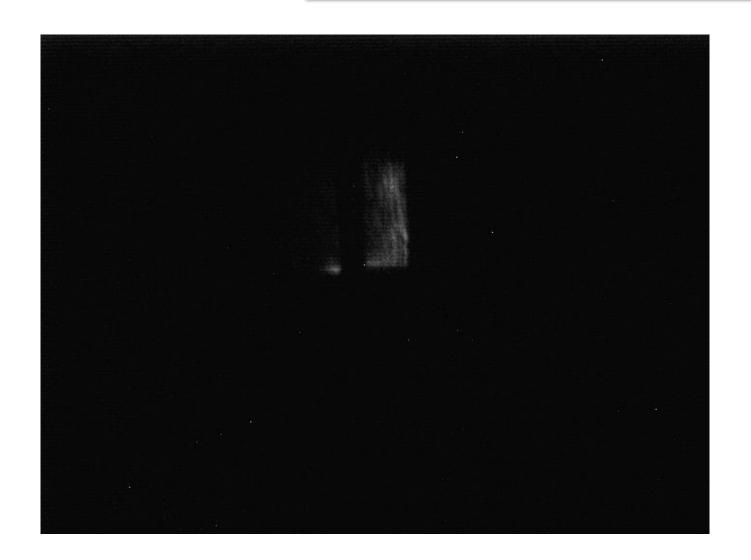
- Silicon Carbide
- Laser machining
- Not etched (orientated perpendicular to beam)
- Mask aperture = 4 * target aperture
 → avoid destructive interference (ODRI)





Beam lifetime

Beam lifetime with target inserted ≈ 2-3 minutes



Conclusion

- Phase 1 hardware and instrumentation for DR experimental program have been installed and tested in CesrTA.
- A method of beam alignment in the target aperture has been established.
- The typical beam lifetime is 2-3 minutes with the target inserted.
- DR signals have been identified from SR background in target images.

Outlook

- Improvements were made to the optical system:
 - A plano-convex lens with 500 mm focal length will be used for improved angular resolution.
 - All optical components have 50 mm clear aperture to avoid clipping.
 - The whole system was also dismantled and realigned.
 - Turn-by-turn measurements using gating
- Preparations for DR angular distribution beam size measurements in winter 2013 are on-going.
- Testing different substrates for the target and ceramic target holders
- Comparison of simulations with experimental data ODRI, suppression of SR
- Going to shorter wavelengths (≈230 nm) to improve beam size sensitivity

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T. Aumeyr, P. Karataev

Thank you for your attention